Customer No. 22,852

Attorney Docket No.: 04329.3247

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)
Katsuyuki SEKINE et al.	) Group Art Unit: Not Yet Assigned
Serial No.: Not Yet Assigned	) Examiner: <b>Not Yet Assigned</b>
Filed: February 25, 2004	) )
For: SEMICONDUCTOR DEVICE AND MANUFACTURING METHOD THEREOF	) ) )

MAIL STOP PATENT APPLICATION Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. § 1.97(b)

Pursuant to 37 C.F.R. §§1.56 and 1.97(b), applicants bring to the Examiner's attention the documents listed on attached Form PTO-1449. Copies of the listed documents are attached. Applicants respectfully request that the Examiner consider the documents listed on attached Form PTO-1449 and indicate that they were considered by making an appropriate notation on this form. This Information Disclosure Statement is being filed with the above-referenced application.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that each or all of the listed documents are material or constitute "prior art." If the Examiner applies any of the documents as prior art against any claim in the application and applicants determine that the cited documents do not constitute "prior art" under United States law, applicants

FINNEGAN HENDERSON FARABOW GARRETT & DUNNER LP

1300 I Street, NW Washington, DC 20005 202.408.4000 Fax 202.408.4400 www.finnegan.com

Customer No. 22,852

Attorney Docket No.: 04329.3247

reserve the right to present to the office the relevant facts and law regarding the appropriate status of such documents. Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed documents, should one or more of the documents be applied against the claims of the present application.

If there is any fee due in connection with the filing of this Statement, please charge the fee to our Deposit Account No. 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW, GARRETT & DUNNER, L.L.P.

Dated: February 25, 2004

ated. February 25, 2004

Enclosures RVB/FPD/sci Richard V. Burgujian Reg. No. 31,744

ERNEST F. CHAPMAN Reg. No. 25,961

FINNEGAN HENDERSON FARABOW GARRETT & DUNNER LLP

1300 I Street, NW Washington, DC 20005 202.408.4000 Fax 202.408.4400 www.finnegan.com

## **INFORMATION DISCLOSURE CITATION**

Atty. Docket No.	04329.3247 Serial No. Not Yet Assigned			
Applicants	Katsuyuki SEKINE et al.			
Filing Date	February 25, 2004	Group:	Not Yet Assigned	

U.S. PATENT DOCUMENTS						
Examiner Initial*	Document Number	Issue Date	Name	Class	Sub Class	Filing Date If Appropriate

FOREIGN PATENT DOCUMENTS						
	Document Number	Publication Date	Country	Class	Sub Class	Translation Yes or No
						· · · · · · · · · · · · · · · · · · ·
				<del>-</del>		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)				
YASUDA, Y. et al., "Radical Nitridation in Multi-Oxide Process for 100nm Generation CMOS Technology", 2001 Symposium on VLSI Technology Digest of Technical Papers, 2 pages, (2001).				
CHEN, C. H. et al., "Downscaling Limit of Equivalent Oxide Thickness in Formation of Ultrathin Gate Dielectric by Thermal-Enhanced Remote Plasma Nitridation", IEEE Transactions on Electron Devices, Vol. 49, No. 5, pp. 840-846, (May 2002).				

Examiner		Date Considered			
*Examiner:	Initial if reference co through citation if no communication to ap	ce considered, whether or not citation is in conformance with MPEP 609; draw line if not in conformance and not considered. Include copy of this form with next to applicant.			
Form PTO 14	149	Patent and Trademark Office - U.S. Department of Commerce			